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Combinatorial pulsed laser deposition of doped yttrium iron garnet films on yttrium aluminium garnet

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We investigate the crystalline growth of yttrium iron garnet (YIG) films doped with bismuth (Bi) and cerium (Ce) by combinatorial pulsed laser deposition, co-ablating a YIG target and either a Bi₂O₃ or a CeO₂ target, for applications in microwave and optical communications. Substrate temperature is critical for crystalline growth of YIG with simultaneous inclusion of Bi in the garnet lattice, whereas Ce is not incorporated in the garnet structure, but forms a separate CeO₂ phase. © 2014 AIP Publishing LLC. [<http://dx.doi.org/10.1063/1.4864134>]

I. INTRODUCTION

Magneto-optic garnets, such as yttrium iron garnet (YIG—Y₃Fe₅O₁₂), find applications in microwave devices (e.g., circulators and magneto-static wave filters)^{1,2} and optical communications (e.g., Faraday rotators and isolators).^{3,4} In the latter field, the Faraday rotation can be increased by substituting yttrium (Y) atoms in the YIG lattice with bismuth (Bi)⁵ or cerium (Ce).⁶ In particular, it has been demonstrated that the Verdet constant increases linearly with doping concentration.⁶

Unlike liquid phase epitaxy,⁷ where film growth happens in thermodynamic equilibrium, Pulsed Laser Deposition (PLD)⁸ allows the growth of thermodynamically unstable materials, such as Bi:YIG and Ce:YIG even up to fully substituted garnets, such as BIG (Bi₃Fe₅O₁₂), as already demonstrated in Ref. 9. Moreover, PLD has already proven to be a reliable film growth method for growing high-quality materials for lasing devices¹⁰ and is a relatively inexpensive, fast, and versatile deposition technique, whose set-up can be adjusted so that different targets can be ablated with different lasers either synchronously or sequentially, in order to tune material composition^{11,12} or grow multi-layer structures,^{13,14} respectively.

We already optimized the growth of YIG on YAG (100)-oriented substrates by single-beam, single-target PLD in Ref. 15, where we observed a Fe-deficiency in all samples. Further experiments were conducted in our multi-beam, multi-target PLD (multi-PLD) system in order to observe the change of YIG film properties with composition.¹¹

In this paper, we discuss our results on growth of doped YIG films by multi-PLD, by co-ablating a YIG target and either a Bi₂O₃ target or a CeO₂ target. In particular, we show how the substrate temperature affects the doping level and the crystalline growth of Bi:YIG films; our multi-PLD attempts of growing Ce:YIG showed also that Ce is not incorporated as Ce³⁺ in the garnet lattice, but forms a separate crystalline CeO₂ phase intermixed with the YIG phase, thus disrupting magnetic properties, such as domain wall nucleation and motion, of the iron garnet.

II. EXPERIMENTAL TECHNIQUES

All YIG films were grown on 10 × 10 mm² × 1 mm-thick YAG (100) substrates in our combinatorial (multi-PLD) system, described in detail in Ref. 16. A frequency-quadrupled Nd:YAG laser, Continuum Surelite II-10 operating at $\lambda = 266$ nm (~ 5 ns pulse duration) with a fixed pulse repetition rate of 10 Hz, was used to ablate a polycrystalline YIG target (99.99% purity, Testbourne Ltd.); the Bi₂O₃ and the CeO₂ targets (99.99% purity, Testbourne Ltd.) were ablated by a Coherent CompexPro 102F KrF excimer laser operating at $\lambda = 248$ nm (20 ns pulse duration), whose repetition frequency f_{KrF} can be changed from 1 Hz to 20 Hz. A Synrad J48-2W carbon dioxide (CO₂) laser operating at 10.6 μm (max. output power: 40 W) was used to heat the substrate during the deposition. The distance between target and substrate was fixed at $d \approx 4$ cm. The Nd:YAG laser fluence was set at $F_{\text{Nd:YAG}} \approx (1.1-1.2)$ J/cm². The excimer laser fluence was set at $F_{\text{KrF}} \approx 2.1$ J/cm² for Bi:YIG experiments and $F_{\text{KrF}} \approx 1.0$ J/cm² for Ce:YIG depositions. The vacuum chamber was pumped down to a base pressure below 0.01 Pa and then filled with flowing oxygen gas at a pressure of $P_{\text{O}_2} \approx 3.4$ Pa. The other growth conditions, i.e., substrate temperature (T) and KrF laser repetition rate, were changed to allow a parametric evaluation of optimum growth of Bi:YIG; for Ce:YIG depositions substrate temperature was set at the maximum value allowed in our multi-PLD system ($T \approx 1150$ K). All films were grown in 2 h (i.e., ~ 72 000 Nd:YAG laser pulses), unless otherwise stated.

Optical microscopy and SEM (Zeiss Evo 50) were used for surface analysis of our samples. Compositional analysis was performed by EDX (Oxford Instruments INCA PentaFETx3): the instrument was energy-calibrated with a cobalt stub before measurements and the YIG target and a blank YAG substrate were used for reference; oxygen concentration was assumed constant at 12 formula units and accuracy on the concentration of other elements (Bi, Ce, Y, and Fe) is estimated to be ~ 0.04 formula units. Crystallographic analysis was performed by XRD (Bruker D2 Phaser), providing a resolution of 0.01°. A description of the set-up used to measure ferromagnetic resonance (FMR) linewidth, used as a film quality indicator (accuracy is ~ 0.1 mT), can be found in Refs. 11 and 15.

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TABLE I. Deposition conditions, FMR linewidth (ΔH), composition [formula units], colour of Bi:YIG samples BY1-9 and of YIG samples Y1, Y4, and Y5, used as a reference.

Sample	Estimated substrate temperature [K]	f_{KrF} [Hz]	ΔH [mT]	Bi conc.	Y conc.	Fe conc.	Sample colour
Y1	1150	0	4.7	0	3.37	4.63	Yellow
BY1a	1150	1	6.2	0.07	3.32	4.61	Yellow
BY1b	1150	2	6.2	0.13	3.27	4.60	Yellow
BY2	1050	1	7.9	0.07	3.36	4.57	Yellow
BY3	1000	1	10.0	0.06	3.27	4.66	Yellow
Y4	950	0	19.2	0	3.31	4.69	Yellow
BY4	950	1	13.2	0.22	3.20	4.57	Yellow
Y5	900	0	23.4	0	3.29	4.71	Dark yellow
BY5a	900	1	8.8	0.22	3.45	4.32	Yellow
BY5b	900	2	10.4	0.30	3.33	4.38	Yellow
BY6	875	1	12.2	0.30	3.28	4.42	Yellow
BY7	850	1	54.5	1.49	3.04	3.47	Dark yellow
BY8	750	1	...	2.94	2.14	2.91	Orange/red
BY9	300	1	...	3.16	1.96	2.88	Black/red

III. RESULTS AND DISCUSSION

A. Bi:YIG

When growing films containing Bi, the melting points of metallic Bi ($T_{\text{m,Bi}} \approx 545$ K) and of its oxide ($T_{\text{m,Bi}_2\text{O}_3} \approx 1090$ K) must be taken into account; moreover, the depression of melting point of nanoparticles and materials in thin-film form must be considered too. Heating the substrate at temperatures $T > T_{\text{m,Bi}_2\text{O}_3}$ will lead to re-evaporation of both Bi and Bi_2O_3 species impinging on the substrate.

Attempts at growing Bi_2O_3 tester samples on *c*-cut sapphire ($\alpha\text{-Al}_2\text{O}_3$) resulted in no film growth at temperatures $T \geq 1000$ K: although optical microscopy and profilometry revealed the presence of particulates scattered across the substrate surface, no film was revealed by stylus profiler and XRD analysis. Room temperature (RT) deposition allowed the growth of Bi_2O_3 on sapphire at a high deposition rate (~ 0.21 nm/pulse), but with an amorphous phase, as revealed by XRD analysis (no diffraction peak between $2\theta = 20^\circ$ and 80°) of a ~ 15 μm -thick film grown in 1 h at 20 Hz.

Following these first trials, we tried depositing Bi:YIG on YAG (100) substrates over a wide range of substrate temperatures, from RT up to the maximum $T \approx 1150$ K, fixing

the KrF laser repetition rate at 1 Hz for most depositions: The results are summarised in Table I, where pure YIG samples Y1, Y4, and Y5, grown under the same conditions as BY1a, BY4, and BY5a, respectively, are listed for reference. Samples BY1b and BY5b were grown under the same conditions as BY1a and BY5a, respectively, but with the KrF laser set at 2 Hz.

All Bi:YIG samples grown at temperature $T \geq 875$ K feature the yellow colour typical of Fe-deficient YIG films,¹⁵ whereas the reference YIG sample Y5 is dark yellow at $T \approx 900$ K. At $T \approx 850$ K, the Bi:YIG film colour becomes darker and then orange with a red tint at $T \approx 750$ K. The sample grown at RT (~ 300 K), although showing good specular reflection, in transmission appears black with a faint red tint (effectively zero transmission). As already shown in Ref. 15, the film colour is an indicator of crystal quality. XRD analysis showed that Bi:YIG samples BY1-BY6 only have crystalline YIG (100) peaks, whereas the XRD pattern of BY7 (shown in Figure 1) features two distinct BIG and YIG peaks, respectively, at $2\theta \approx 28.24^\circ$ and $2\theta \approx 28.86^\circ$. BY8 shows no evidence of any garnet phase, with only a peak at $2\theta \approx 29.2^\circ$, that can be attributed to (111)-oriented Y_2O_3 (shown via the (222) peak, as in Figure 1); BY9 does not show any crystalline phase, as no diffraction peaks are observed in its XRD pattern, except for those attributable to the YAG substrate. Table II shows the database peak positions for BIG (400), YIG (400), YAG (400), and Y_2O_3 (222) for reference.

XRD analysis of samples BY1-BY6, grown at $T \geq 875$ K, showed a shift of the YIG peak position with changing substrate temperature, as shown in Figure 2: while the XRD patterns of pure YIG samples Y1, Y4, and Y5 feature a YIG (400) peak at roughly the same diffraction angle,

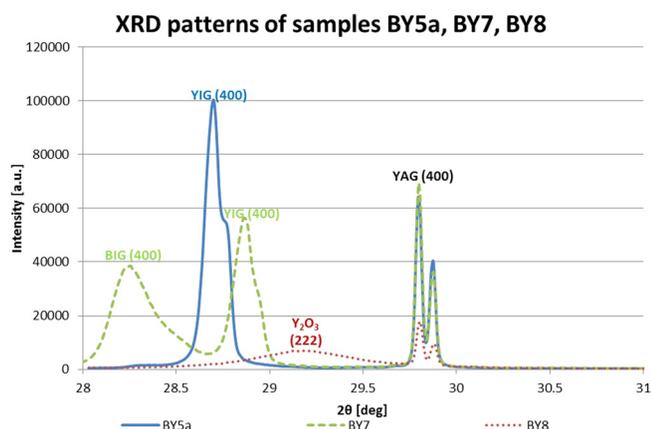


FIG. 1. Comparison of XRD patterns of BY5a, BY7, and BY8. Peak doublets are due to Cu-K₂₂ radiation present in the diffractometer.

TABLE II. Database peak positions for BIG, YIG, and YAG (100) phases and Y_2O_3 (111) and relative references.

XRD peak	BIG (400)	YIG (400)	YAG (400)	Y_2O_3 (222)
Database peak position	28.22°	28.90°	29.80°	29.20°
References	17	18	19	20

YIG peak position vs. substrate temperature

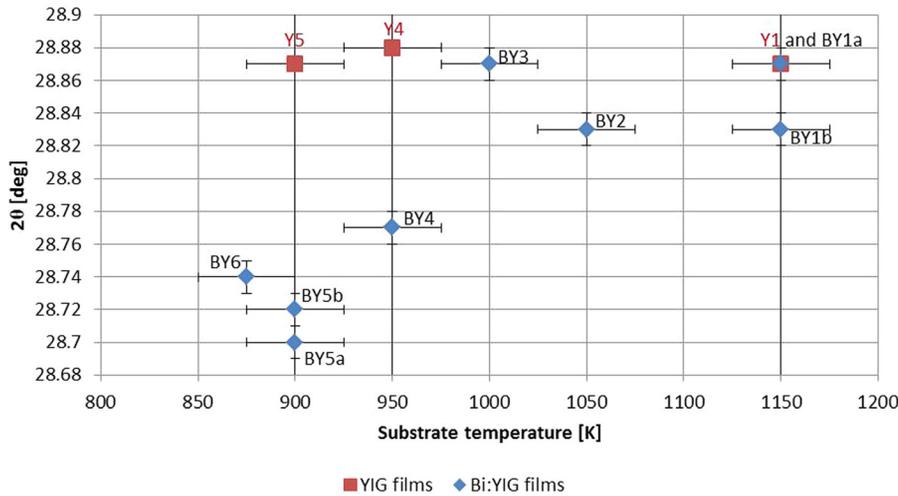


FIG. 2. Trend of YIG (400) peak position in the XRD patterns of YIG and Bi:YIG films with substrate temperature. Error bars are shown: $\Delta T = \pm 25$ K, $\Delta 2\theta = \pm 0.01^\circ$.

the YIG (400) peak in Bi:YIG films tends to shift towards lower diffraction angles with decreasing substrate temperature, implying an increase in lattice constant.

Figure 3 shows the variation of film composition for Bi:YIG samples grown at $f_{KrF} = 1$ Hz with substrate temperature. As shown also in Table I, the film composition changes dramatically with temperature and a transition region is clearly observed around $T \approx 850$ K, the same range of temperature where the change in crystallinity is observed, as discussed above.

Figure 4 shows the trend of FMR linewidth with substrate temperature: as already found in Ref. 15 for pure YIG films grown by PLD with a KrF laser, FMR linewidth tends to increase with decreasing temperature, but more slowly for Bi:YIG films, compared with pure YIG (Y1, Y4, and Y5); also, at a temperature $T \approx 900$ K, there appears to be a local minimum for FMR linewidth, as opposed to the values for pure YIG, where the lowest value is at $T \approx 1150$ K and increases steadily with decreasing temperature.

The observed phenomena require further discussion to try to identify the primary cause of change of YIG properties

with substrate temperature, Bi concentration, and crystallinity. At very high temperatures ($T \geq 1000$ K), only a small fraction of the bismuth present within the plume is incorporated into the final garnet structure, because of re-evaporation from the hot surface of the sample, resulting in a very low doping level (~ 0.07 formula units—see Table I), which causes a small change in lattice constant (see Figure 2), due to the larger ionic radius of Bi, compared with Y. This doping level is also too low to cause a significant change in magnetic properties and FMR linewidth ΔH initially increases with decreasing temperature (see Figure 4), as already observed in Ref. 15 for YIG films. At $T \approx (900-950)$ K, the Bi doping increases by a factor of ~ 3 (~ 0.22 formula units—see Table I), suggesting that the substrate temperature is closer to the melting point of Bi_2O_3 in thin-film form, and the lattice constant increases accordingly (as seen in the large YIG (400) peak shift in Figure 2, $\sim 0.17^\circ$ between BY5a and BY1a); it is at $T \approx 900$ K (BY5a) that the local minimum of $\Delta H(T)$ is observed and this can be explained with the change in YIG film properties with Bi doping. Also, our results agree with previous findings in the literature of PLD growth of Bi:YIG by single-beam

Composition vs. substrate temperature

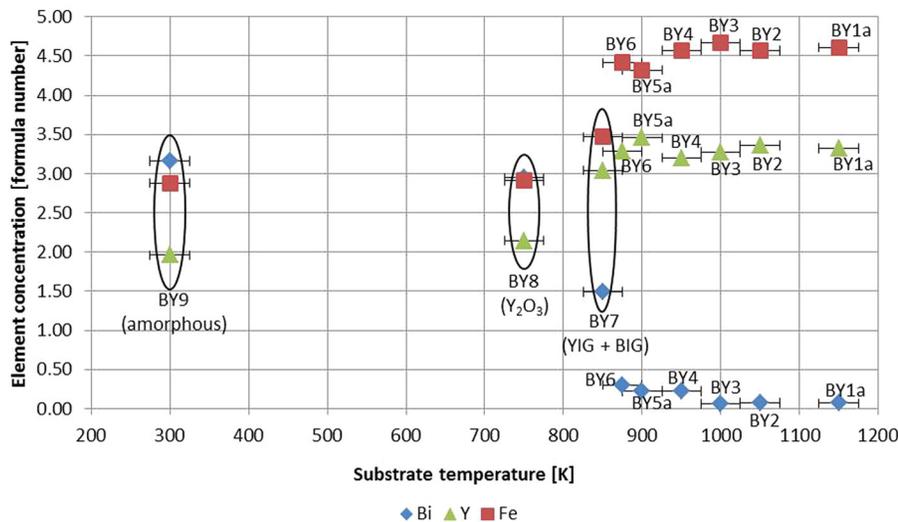


FIG. 3. Trend of composition with substrate temperature. The samples highlighted with ellipses have peculiar crystallinity, as shown here and in Figure 1. Error bars are shown for temperature ($\Delta T = \pm 25$ K); the accuracy of compositional analysis is ± 0.04 formula numbers.

FMR linewidth vs. substrate temperature

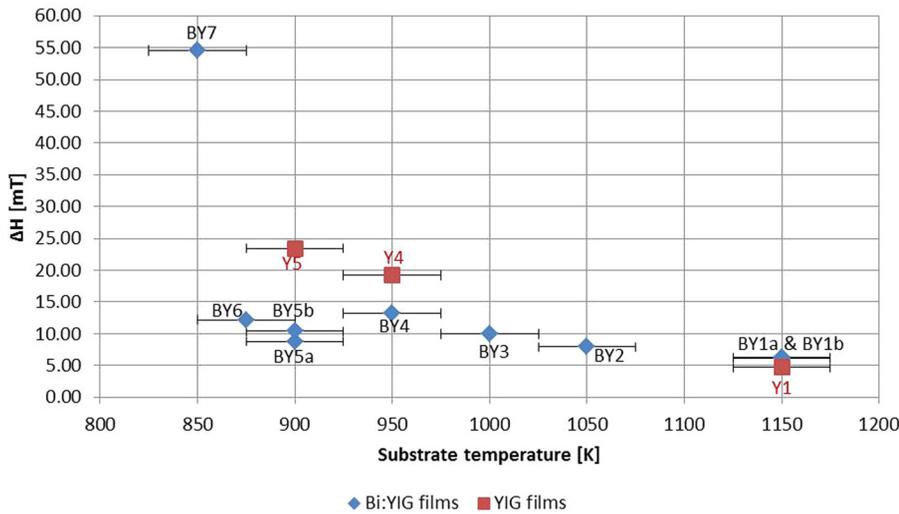


FIG. 4. Trend of FMR linewidth with substrate temperature. Error bars are shown for temperature ($\Delta T = \pm 25$ K); the accuracy of FMR linewidth measurements is ~ 0.1 mT.

single-target PLD, where optimum growth temperatures of ~ 900 K for Bi:YIG on GGG^{21,22} and ~ 1100 K for YIG on GGG^{1,22,23} are reported.

Two factors can be taken into account to explain the change in the FMR linewidth trend with substrate temperature:

- 1) a direct change of magnetic properties of YIG with Bi doping;
- 2) an indirect effect of Bi doping on magnetic properties via a change in crystallinity.

Regarding the first aspect of Bi inclusion, Figure 5 shows the variation of FMR linewidth with Bi concentration: Although there is an increase in FMR linewidth with Bi concentration, the trend is not systematic (e.g., the Bi doping of BY3 is one fifth that of BY5b, but they have roughly the same FMR linewidth); also, there is no significant change in FMR linewidth, when doubling the KrF laser repetition rate (f_{KrF}) and thus doubling the Bi concentration at $T \approx 1150$ K (BY1a and BY1b—see Table I and Figures 4 and 5). Also, when doubling f_{KrF} at $T \approx 900$ K (samples BY5a and BY5b), the Bi concentration increases by $\sim 36\%$, but the

FMR linewidth increases by $\sim 18\%$ (see Table I and Figures 4 and 5), meaning that Bi doping has a more dramatic role when it reaches a level higher than 0.2 formula units.

On the other hand, the second factor is reinforced by a clear change in lattice constant with changing temperature (see Figure 2) and by the decreasing trend of YIG (400) peak position (i.e., an increase in lattice constant) with increasing Bi concentration, shown in Figure 6, as expected from theory, due to the larger ionic radius of Bi compared with Y. While the change in YIG peak position and lattice constant is clearly due to Bi doping, no change in YIG peak position with temperature is observed in pure YIG films (see Figure 2); however, at very high temperature ($T \geq 1000$ K), the deterioration of crystal quality has a stronger effect than that of Bi doping (quite low, ~ 0.07 formula units), which prevails only at $T \approx 900$ K—BY5a, and the observed local minimum of $\Delta H(T)$. A further decrease in temperature causes further deterioration of crystal quality, until at $T \approx 850$ K the substrate temperature probably reaches the depressed melting point of Bi_2O_3 ($T_{\text{m,Bi}_2\text{O}_3}$) and Bi concentration increases abruptly at 1.49 formula units, whereas both Y and Fe

FMR linewidth vs. Bi concentration

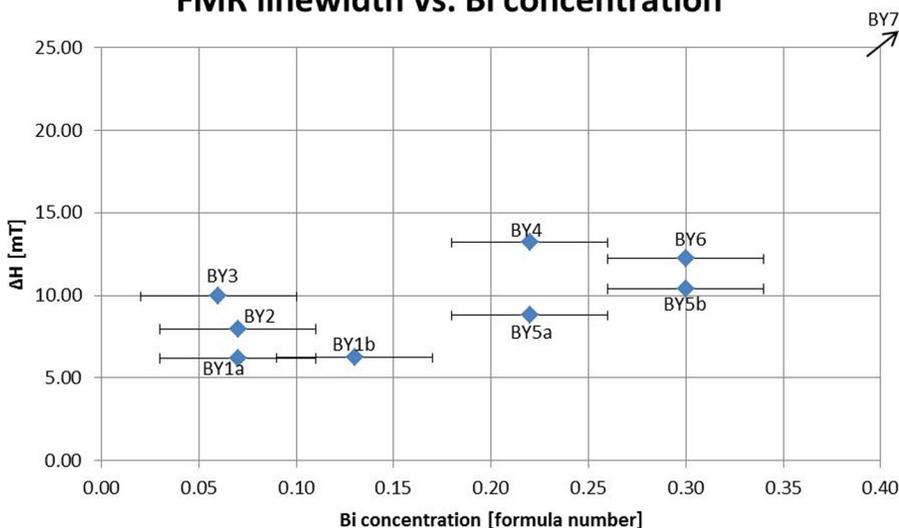


FIG. 5. Trend of FMR linewidth with Bi concentration. Error bars are shown for Bi concentration (± 0.04 formula numbers); the accuracy of FMR linewidth measurements is ~ 0.1 mT.

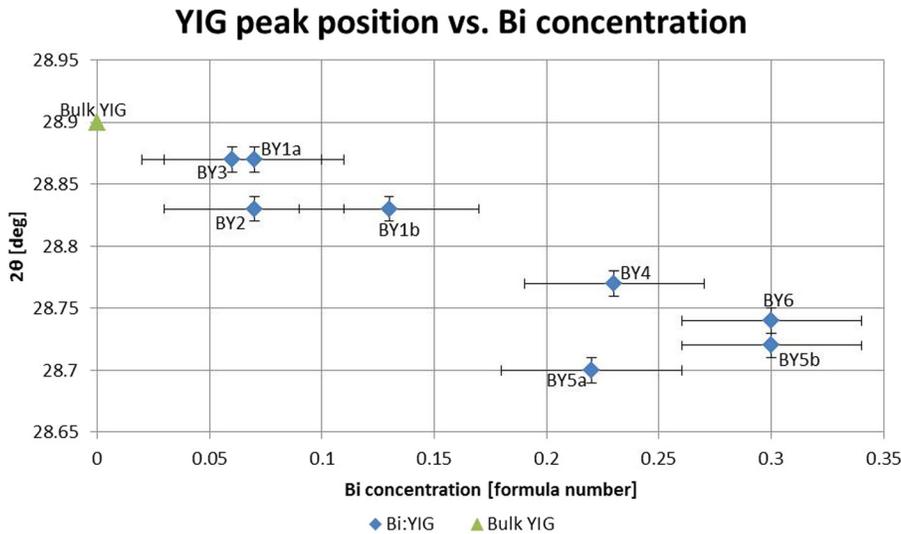


FIG. 6. Trend of YIG (400) peak position with Bi concentration. Error bars are shown for Bi concentration (± 0.04 formula numbers) and $\Delta 2\theta = \pm 0.01^\circ$.

concentration decrease (see BY7 in Table I and Figure 3): This is the most likely cause of the formation of two separate BIG and YIG phases in the film (BY7 in Figure 1), which are detrimental for magnetic properties (see point BY7 in Figure 4). A further decrease in substrate temperature ($T \approx 750$ K) leads to the growth of an yttria phase (see BY8 in Figure 1) heavily doped with Bi and Fe, at similar concentrations (~ 3 formula units—see BY8 in Figure 3). The completely different crystal phase produces no magnetic properties and no FMR absorption. Growth at RT results in an amorphous film (BY9) with composition similar to BY8 and again no FMR.

To sum up, there is a complex interplay between substrate temperature (T), Bi concentration (Bi conc.), YIG peak position (2θ), crystal quality and FMR linewidth (ΔH), whose general trends are summarised schematically in Figure 7.

Finally, we tried to grow a highly doped Bi:YIG film using a substrate temperature $T \approx 900$ K, considered as a compromise between Bi-doping level and crystalline and magnetic properties. Setting the KrF laser repetition rate at $f_{\text{KrF}} = 10$ Hz resulted in a heavily doped Bi:YIG film, with a composition of $\text{Bi}_{2.38}\text{Y}_{2.81}\text{Fe}_{2.81}\text{O}_{12}$, showing a strong Fe deficiency and a low Y-substitutional level, suggesting that Bi is probably substituting Fe rather than Y, as already observed in BY7-BY9. The film featured also an XRD pattern similar to that of BY7, with two separate YIG and BIG peaks, and an FMR linewidth $\Delta H \approx 47.8$ mT. This eventually

suggests that Bi doping level plays a big role: if excessive and substituting for Fe instead of Y, it causes the formation of different crystalline phases, which results in a large broadening of FMR linewidth.

B. Ce:YIG

Cerium and its oxides have higher melting points than bismuth and its oxides: $T_{\text{m,Ce}} \approx 1068$ K, $T_{\text{m,Ce}_2\text{O}_3} \approx 2450$ K, and $T_{\text{m,CeO}_2} \approx 2673$ K, which would therefore indicate that deposition of Ce:YIG films at high temperatures should be feasible. We tried co-ablating the CeO_2 target with the KrF laser set at $F_{\text{KrF}} \approx 1$ J/cm² and $f_{\text{KrF}} = (1-2)$ Hz and the YIG target with the Nd:YAG laser set at $F_{\text{Nd:YAG}} \approx 1.1$ J/cm² and $f_{\text{KrF}} = 10$ Hz. The depositions were performed under the usual near-optimum growth conditions for YIG, i.e., at $T \approx 1150$ K, $P_{\text{O}_2} \approx 3.3$ Pa, and $d \approx 4$ cm.

Both samples grown at $f_{\text{KrF}} = 1$ and 2 Hz feature the typical yellow colour of YIG films, but two clearly distinct phases in the XRD patterns, as shown in Figure 8, and attributable to YIG (100) and CeO_2 (111). This suggests that the Ce^{4+} species ablated from the CeO_2 target are neither reduced nor included in the garnet lattice, but instead they form a separate phase intermixed with the YIG crystal

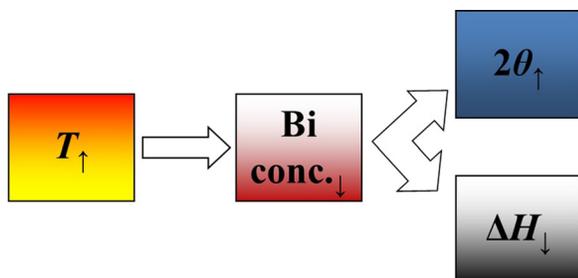


FIG. 7. Schematic of the interplay between substrate temperature (T), Bi concentration (Bi conc.), YIG peak position (2θ), and FMR linewidth (ΔH) in the multi-PLD growth of Bi:YIG.

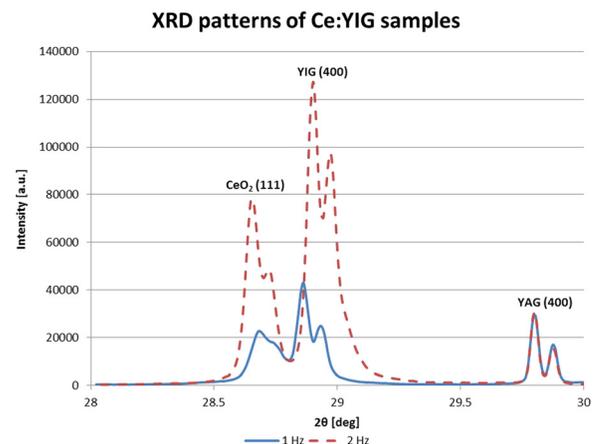


FIG. 8. XRD patterns of Ce:YIG samples. Peak doublets are due to Cu-K_{α2} radiation present in the diffractometer.

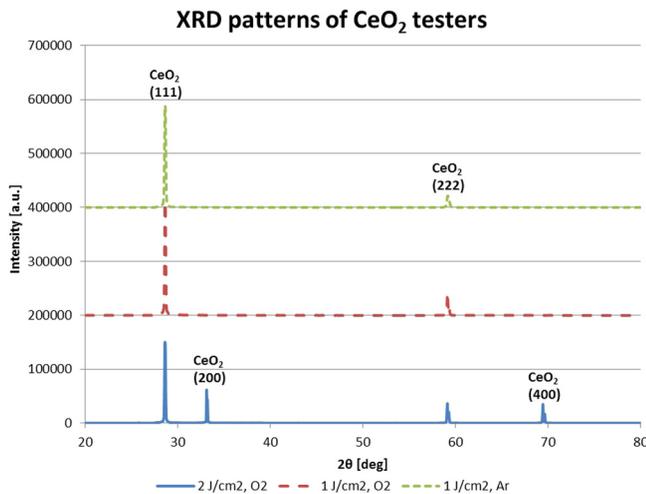


FIG. 9. Comparison of XRD patterns of CeO_2 test films.

structure, resulting in an absence of FMR absorption. The composition of the two films is $\text{Ce}_{0.64}\text{Y}_{3.1}\text{Fe}_{4.26}\text{O}_{12}$ and $\text{Ce}_{1.61}\text{Y}_{2.67}\text{Fe}_{3.72}\text{O}_{12}$ for the samples grown, respectively, at $f_{\text{KrF}} = 1$ Hz and $f_{\text{KrF}} = 2$ Hz, showing that, as in Bi:YIG films, not only the concentration of Y, but also that of Fe tends to decrease with increasing level of Ce doping.

No further multi-PLD experiments were performed for Ce inclusion because no FMR absorption was observed in our intended Ce:YIG samples; we instead investigated the ablation of the CeO_2 target and the growth of cerium oxide on *c*-cut sapphire substrates, heated at high temperature ($T \approx 1150$ K).

The CeO_2 target was ablated with the KrF laser, set at $f_{\text{KrF}} = 20$ Hz and different fluences ($F_{\text{KrF}} \approx 1$ and 2 J/cm^2), and with different background gases (oxygen, O_2 , and argon, Ar). XRD analysis (see Figure 9) showed that the film grown in O_2 at $F_{\text{KrF}} \approx 2 \text{ J/cm}^2$ is polycrystalline CeO_2 with two different orientations: (111) and (100). When depositing at lower fluence ($F_{\text{KrF}} \approx 1 \text{ J/cm}^2$), either in O_2 or Ar, the film grows as CeO_2 (111). For all cases however, as confirmed also by EDX, the film composition was CeO_2 , meaning that Ce species ablated from the CeO_2 target maintain the 4+ valence state, even in an Ar ambient, as reported in literature for a wide range of deposition conditions.^{24–28} Growth rates were ~ 0.069 nm/pulse and ~ 0.035 nm/pulse in O_2 , respectively, at $F_{\text{KrF}} \approx 2 \text{ J/cm}^2$ and 1 J/cm^2 , and ~ 0.028 nm/pulse in Ar at $F_{\text{KrF}} \approx 1 \text{ J/cm}^2$.

The results of depositions of cerium oxide on sapphire substrates under different conditions confirmed what we had already observed in the attempts of growing Ce:YIG films: the cerium in the plume is incorporated in the film as crystalline CeO_2 with (111) preferential orientation.

IV. CONCLUSIONS

We have investigated the possibility of growing doped YIG films by combinatorial PLD, in particular, the growth of Bi:YIG and Ce:YIG by co-ablation of a YIG target with a frequency-quadrupled Nd:YAG laser and either a Bi_2O_3 or a CeO_2 target with a KrF laser.

The re-evaporation of Bi from the hot substrate surface limits the Bi-doping level at the high temperatures needed

for optimum YIG growth, due to the lower melting points of Bi and its oxide. Lower substrate temperatures cause an increase in Bi concentration, but also degraded crystal quality and a resultant higher FMR linewidth. We found a compromise at a local minimum of FMR linewidth vs. substrate temperature ($T \approx 900$ K), before a critical deterioration of crystal quality and magnetic properties takes place; however, increasing the Bi-doping at this temperature will deteriorate both crystallinity and FMR, probably due to the fact that Bi is replacing not only Y but also Fe atoms in the YIG lattice. This could be overcome by multi-PLD of Bi_2O_3 , Y_2O_3 , and Fe_2O_3 and ablating the three targets sequentially one at a time, in order to grow monolayers of each material and thus an artificial Bi:YIG crystal; however, the film growth rate would be considerably lower.

Ce and its oxides have higher melting points than Bi and Bi_2O_3 , thus allowing growth of heavily doped Ce:YIG at high temperatures. However, the lack of Ce_2O_3 targets and the fact that the ablated species from a CeO_2 target maintain their 4+ valence state do not allow the inclusion of Ce into the YIG lattice as Ce^{3+} , so that multi-PLD of YIG and CeO_2 produces polycrystalline films with intermixed CeO_2 and YIG phases and no FMR. The problem may be overcome using a metallic Ce target, although it tarnishes slowly in air, its ablation may cause formation of droplets and its ablated species may be easily oxidised in the wrong valence state in oxygen; however, multi-PLD growth of Ce:YIG may be feasible in Ar.

The results presented in this paper show the potentials of multi-PLD to grow materials with engineered composition, for example, in microwave and magneto-optic applications. However, care must be taken in the choice of deposition conditions and targets to ensure growth of the desired final material in the correct phase.

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¹S. A. Manuilov, R. Fors, S. I. Khartsev, and A. M. Grishin, *J. Appl. Phys.* **105**, 033917 (2009).

²G. B. G. Stenning, G. J. Bowden, L. C. Maple, S. A. Gregory, A. Sposito, R. W. Eason, N. I. Zheludev, and P. A. J. De Groot, *Opt. Express* **21**, 1456 (2013).

³B. Lei, H. Juejun, J. Peng, K. Dong Hun, G. F. Dionne, L. C. Kimerling, and C. A. Ross, *Nat. Photonics* **5**, 758 (2011).

⁴H. Dotsch, N. Bahlmann, O. Zhuromskyy, M. Hammer, L. Wilkens, R. Gerhardt, P. Hertel, and A. F. Popkov, *J. Opt. Soc. Am. B* **22**, 240 (2005).

⁵H. Hayashi, S. Iwasa, N. J. Vas, T. Yoshitake, K. Ueda, S. Yokoyama, S. Higuchi, H. Takeshita, and M. Nakahara, *Appl. Surf. Sci.* **197–198**, 463 (2002).

⁶S. Higuchi, K. Ueda, F. Yahiro, Y. Nakata, H. Uetsuhara, T. Okada, and M. Maeda, *IEEE Trans. Magn.* **37**, 2451 (2001).

⁷H. X. Wei and W. S. Wang, *IEEE Trans. Magn.* **20**, 1222 (1984).

- ⁸*Pulsed Laser Deposition of Thin Films—Applications-Led Growth of Functional Materials*, edited by R. W. Eason (Wiley Interscience, 2007).
- ⁹S. Kahl and A. M. Grishin, *J. Appl. Phys.* **93**, 6945 (2003).
- ¹⁰N. A. Vainos, C. Grivas, C. Fotakis, R. W. Eason, A. A. Anderson, D. S. Gill, D. P. Shepherd, M. Jelinek, J. Lancok, and J. Sonsky, *Appl. Surf. Sci.* **127–129**, 514 (1998).
- ¹¹A. Sposito, S. A. Gregory, G. B. G. Stenning, P. A. J. de Groot, and R. W. Eason, “Compositional tuning of YIG film properties by multi-beam pulsed laser deposition,” *Thin Solid Films* (submitted).
- ¹²M. S. B. Darby, T. C. May-Smith, and R. W. Eason, *Appl. Phys. A: Mater. Sci. Process.* **93**, 477 (2008).
- ¹³K. A. Sloyan, T. C. May-Smith, M. N. Zervas, and R. W. Eason, *Appl. Phys. Lett.* **101**, 081117 (2012).
- ¹⁴K. A. Sloyan, T. C. May-Smith, M. Zervas, R. W. Eason, S. Huband, D. Walker, and P. A. Thomas, *Opt. Express* **18**, 24679 (2010).
- ¹⁵A. Sposito, T. C. May-Smith, G. B. G. Stenning, P. A. J. de Groot, and R. W. Eason, *Opt. Mater. Express* **3**, 624 (2013).
- ¹⁶T. C. May-Smith, K. A. Sloyan, R. Gazia, and R. W. Eason, *Cryst. Growth Des.* **11**, 1098 (2011).
- ¹⁷H. Toraya and T. Okuda, *J. Phys. Chem. Solids* **56**, 1317 (1995).
- ¹⁸D. Rodic, M. Mitric, R. Tellgren, H. Rundloef, and A. Kremenovic, *J. Magn. Magn. Mater.* **191**, 137 (1999).
- ¹⁹L. Dobrzycki, E. Bulska, D. A. Pawlak, Z. Frukacz, and K. Wozniak, *Inorg. Chem.* **43**, 7656 (2004).
- ²⁰G. Baldinozzi, J. F. Berar, and G. Calvarin, *Mater. Sci. Forum* **278–281**, 680 (1998).
- ²¹E. Popova, L. Magdenko, H. Niedoba, M. Deb, B. Dagens, B. Berini, M. Vanwollegem, C. Vilar, F. Gendron, A. Fouchet, J. Scola, Y. Dumont, M. Guyot, and N. Keller, *J. Appl. Phys.* **112**, 093910 (2012).
- ²²B. M. Simion, G. Thomas, R. Ramesh, V. G. Keramidas, and R. L. Pfeffer, *Appl. Phys. Lett.* **66**, 830 (1995).
- ²³S. Yiyang, S. Young-Yeal, C. Houchen, M. Kabatek, M. Jantz, W. Schneider, W. Mingzhong, H. Schultheiss, and A. Hoffmann, *Appl. Phys. Lett.* **101**, 152405 (2012).
- ²⁴S. Amirhaghi, Y. H. Li, J. A. Kilner, and I. W. Boyd, *Mater. Sci. Eng. B* **34**, 192 (1995).
- ²⁵R. P. Wang, S. H. Pan, Y. L. Zhou, G. W. Zhou, N. N. Liu, K. Xie, and H. B. Lu, *J. Cryst. Growth* **200**, 505 (1999).
- ²⁶D. Q. Shi, M. Ionescu, J. McKinnon, and S. X. Dou, *Physica C* **356**, 304 (2001).
- ²⁷T. Chaudhuri, S. Phok, and R. Bhattacharya, *Thin Solid Films* **515**, 6971 (2007).
- ²⁸Y. T. Ho, K. S. Chang, K. C. Liu, L. Z. Hsieh, and M. H. Liang, *Cryst. Res. Technol.* **48**, 308 (2013).